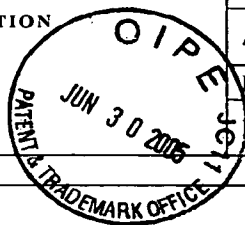


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**U.S. PATENT DOCUMENTS**

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FOREIGN PATENT DOCUMENTS

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OTHER DOCUMENTS (including Author, Title, Date, Pertinent Pages, etc.)

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	/D.L.L./	#1="Electronic Functional Materials", The Society of Polymer Science Japan, Kyoritsu Shuppan Co., Ltd., 1992, pp.279-290
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